



GaAs pHEMT MMIC 2 WATT POWER AMPLIFIER, 27.5 - 31 GHz

Typical Applications

The HMC7441 is ideal for:

- Point-to-Point Radios
- Point-to-Multi-Point Radios
- VSAT & SATCOM
- Military & Space

Features

Saturated Output Power: +34 dBm @ 25% PAE

High Output IP3: +38 dBm

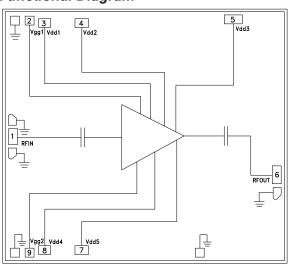
High Gain: 23 dB

DC Supply: +6V @ 1000 mA

No External Matching Required

Die Size: 3.18 x 2.84 x 0.1 mm

Functional Diagram



General Description

The HMC7441 is a three-stage GaAs pHEMT Power Amplifier which operates between 27.5 and 31 GHz. The amplifier provides 23 dB of gain and +34 dBm of saturated output power at 25% PAE from a 6V supply. With an excellent output IP3 of +38 dBm, the HMC7441 is ideal for linear application such as Kaband VSAT or high capacity point-to-point or point-to-multi-point radios demanding +34 dBm of efficient saturated output power. The RF I/Os are DC blocked and matched to 50 Ohms for ease of integration into Multi-Chip-Modules (MCMs). All data is taken with the chip in a 50 Ohm test fixture connected via (1) 0.025mm (1 mil) diameter wire bonds of 0.31 mm (12 mil) length.

Electrical Specifications, $T_A = +25^{\circ}$ C Vdd = Vdd1, Vdd2, Vdd3, Vdd4, Vdd5 = +6V, Idd = 1000 mA [1]

Parameter	Min.	Тур.	Max.	Units	
Frequency Range		27.5 - 31		GHz	
Gain	20	23		dB	
Gain Variation Over Temperature		0.03		dB/ °C	
Input Return Loss		8		dB	
Output Return Loss		8		dB	
Output Power for 1 dB Compression (P1dB)	31	34		dBm	
Saturated Output Power (Psat)		34		dBm	
Output Third Order Intercept (IP3) ^[2]		38		dBm	
Total Supply Current (Idd)		1000		mA	
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^[1] Adjust Vgg between -2 to 0V to achieve Idd = 1000 mA typical.

^[2] Measurement taken at +6V @ 1000 mA, Pout / Tone = +28 dBm

HMC7441* PRODUCT PAGE QUICK LINKS

Last Content Update: 02/23/2017

COMPARABLE PARTS 🖵

View a parametric search of comparable parts.

DOCUMENTATION

Application Notes

- AN-1363: Meeting Biasing Requirements of Externally Biased RF/Microwave Amplifiers with Active Bias Controllers
- Broadband Biasing of Amplifiers General Application Note
- MMIC Amplifier Biasing Procedure Application Note
- Thermal Management for Surface Mount Components General Application Note

Data Sheet

• HMC7441 Data Sheet

DESIGN RESOURCES 🖵

- HMC7441 Material Declaration
- PCN-PDN Information
- · Quality And Reliability
- Symbols and Footprints

DISCUSSIONS

View all HMC7441 EngineerZone Discussions.

SAMPLE AND BUY 🖵

Visit the product page to see pricing options.

TECHNICAL SUPPORT

Submit a technical question or find your regional support number.

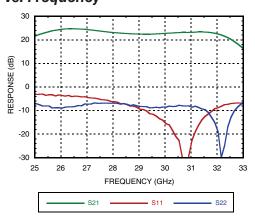
DOCUMENT FEEDBACK 🖳

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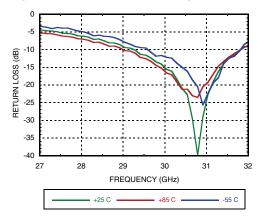




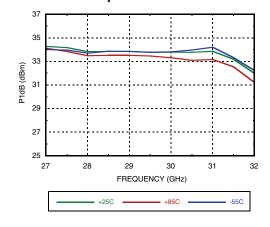
Broadband Gain & Return Loss vs. Frequency



Input Return Loss vs. Temperature

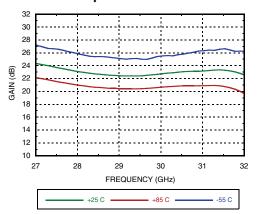


P1dB vs. Temperature

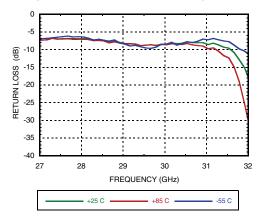


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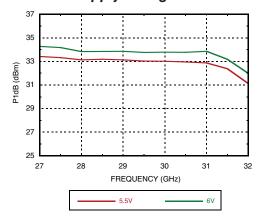
Gain vs. Temperature



Output Return Loss vs. Temperature



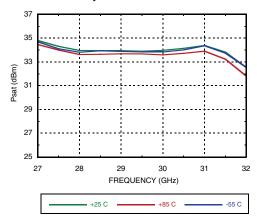
P1dB vs. Supply Voltage



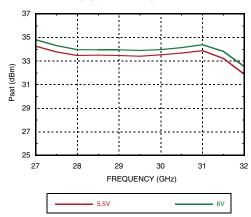




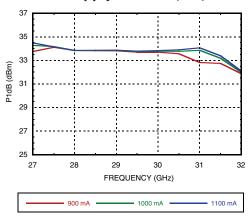
Psat vs. Temperature



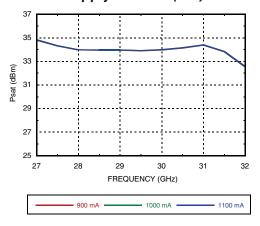
Psat vs. Supply Voltage



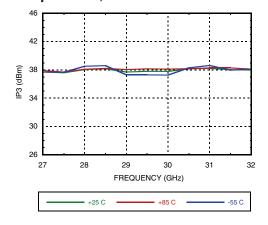
P1dB vs. Supply Current (Idd)



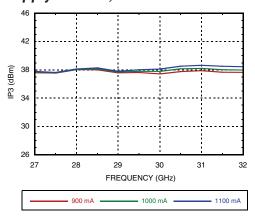
Psat vs. Supply Current (Idd)



Output IP3 vs. Temperature, Pout/Tone = +28 dBm



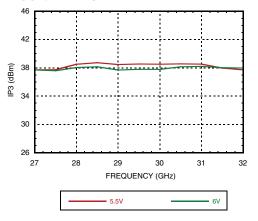
Output IP3 vs.
Supply Current, Pout/Tone = +28 dBm



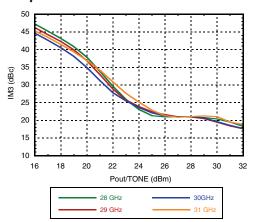




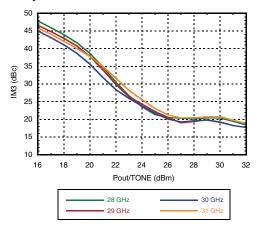
Output IP3 vs.
Supply Voltage, Pout/Tone = +28 dBm



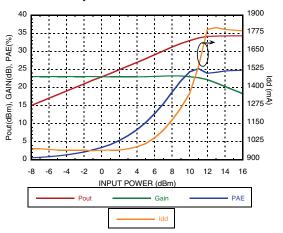
Output IM3 @ Vdd = +5.5V



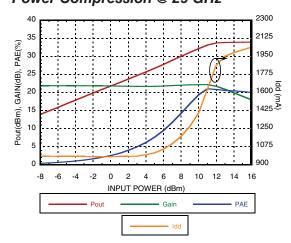
Output IM3 @ Vdd = +6V



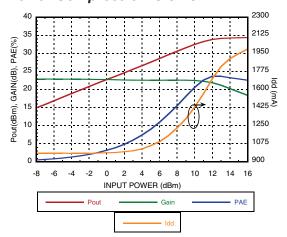
Power Compression @ 27.5 GHz



Power Compression @ 29 GHz



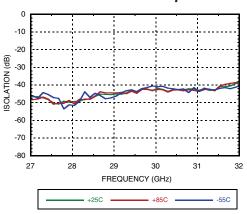
Power Compression @ 31 GHz



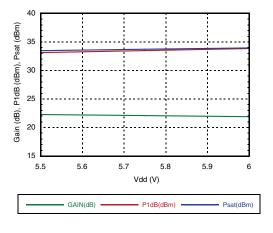




Reverse Isolation vs. Temperature

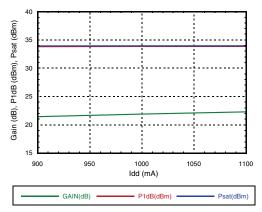


Gain & Power vs. Supply Voltage @ 29 GHz

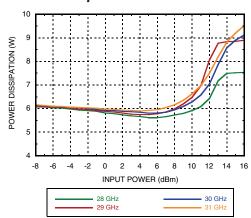


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Gain & Power vs. Supply Current @ 29 GHz



Power Dissipation







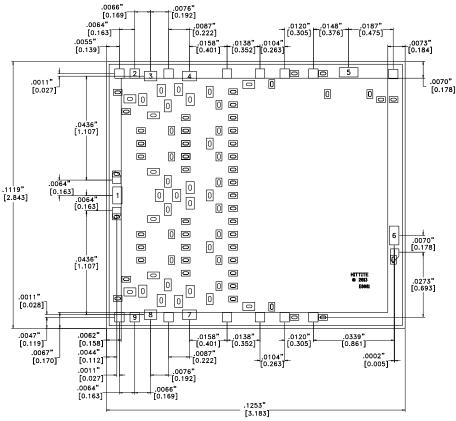
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Absolute Maximum Ratings

Drain Bias Voltage (Vdd)	+6.5V	
RF Input Power (RFIN)	+24 dBm	
Channel Temperature	175 °C	
Continuous Pdiss (T= 85 °C) (derate 125 mW/°C above 85°C)	10.5 W	
Thermal Resistance (channel to die bottom)	8 °C/W	
Storage Temperature	-65 to +150 °C	
Operating Temperature	-55 to +85 °C	
ESD Sensitivity (HBM)	Class 1A, Passed 250V	



Outline Drawing



Die Packaging Information [1]

Standard	Alternate	
GP-1 (Gel Pack)	[2]	

[1] Refer to the "Packaging Information" section for die packaging dimensions.

[2] For alternate packaging information contact Hittite Microwave Corporation.

NOTES:

- 1. ALL DIMENSIONS ARE IN INCHES [MM]
- 2. DIE THICKNESS IS .004"
- 3. TYPICAL BOND PAD IS 0.0026" [0.066] SQUARE
- 4. BACKSIDE METALLIZATION: GOLD
- 5. BOND PAD METALLIZATION: GOLD
- 6. BACKSIDE METAL IS GROUND.
- 7. CONNECTION NOT REQUIRED FOR UNLABELED BOND PADS.
- 8. OVERALL DIE SIZE ± .002

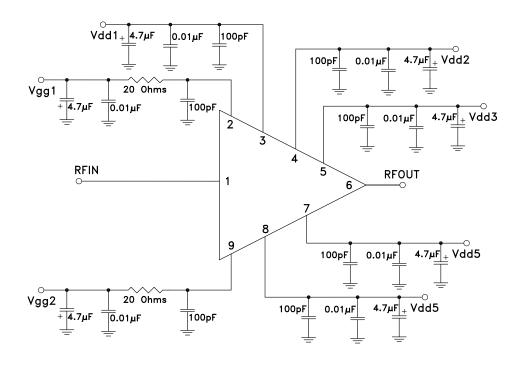




Pad Descriptions

Pad Number	Function	Description	Interface Schematic
1	RFIN	RF signal input. This pin is AC coupled and matched to 50 Ohms over the operating frequency range.	RFIN○— —
2, 9	Vgg1, Vgg2	Gate control for amplifier. Vgg1 and Vgg2. External bypass capacitors of 100pF, 0.01uF, and 4.7uF are required, also required is an in line 20 Ohm resistor, see Application Circuit.	Vgg1,2 0
3, 4, 5, 7, 8	Vdd1-4	Drain bias voltage for the top half of the amplifier. External bypass capacitors of 100pF required for each pin, followed by common 0.01uF and 4.7uF Capacitors.	○Vdd1-5 ————————————————————————————————————
7	RFOUT	RF signal output. This pad is AC coupled and matched to 50 Ohms over the operating frequency range.	○ RFOUT
Die Bottom	GND	Die bottom must be connected to RF/DC ground.	O GND

Application Circuit

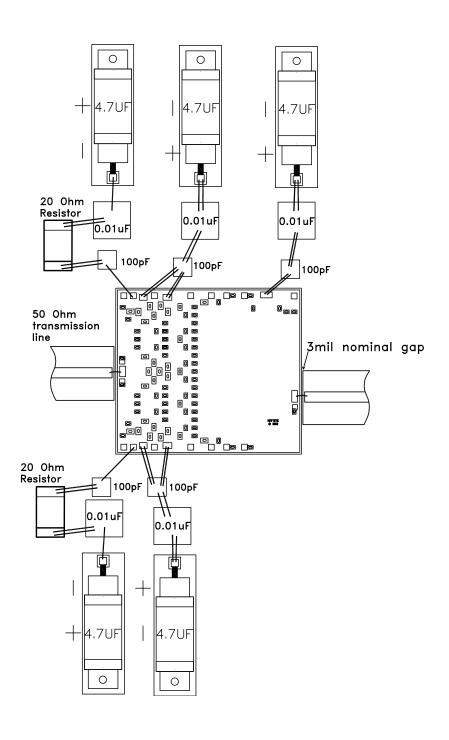




Assembly Diagram

ANALOG DEVICES

GaAs pHEMT MMIC 2 WATT POWER AMPLIFIER, 27.5 - 31 GHz







Mounting & Bonding Techniques for Millimeterwave GaAs MMICs

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102mm (4 mil) thick die to a 0.150mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be located as close to the die as possible in order to minimize bond wire length. Typical die-to-substrate spacing is 0.076mm to 0.152 mm (3 to 6 mils).

Handling Precautions

Follow these precautions to avoid permanent damage.

Storage: All bare die are placed in either Waffle or Gel based ESD protective containers, and then sealed in an ESD protective bag for shipment. Once the sealed ESD protective bag has been opened, all die should be stored in a dry nitrogen environment.

Cleanliness: Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

Static Sensitivity: Follow ESD precautions to protect against $> \pm 250$ V ESD strikes.

Transients: Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pick-up.

General Handling: Handle the chip along the edges with a vacuum collet

or with a sharp pair of bent tweezers. The surface of the chip may have fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

Mounting

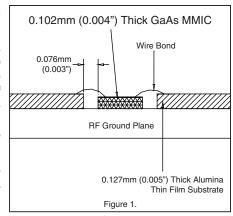
The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

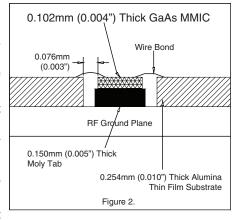
Eutectic Die Attach: A 80/20 gold tin preform is recommended with a work surface temperature of 255°C and a tool temperature of 265°C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290°C. DO NOT expose the chip to a temperature greater than 320°C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

Epoxy Die Attach: Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position. Cure epoxy per the manufacturer's schedule.

Wire Bonding

Ball or wedge bond with 0.025mm (1 mil) diameter pure gold wire. Thermosonic wirebonding with a nominal stage temperature of 150°C and a ball bonding force of 40 to 50 grams or wedge bonding force of 18 to 22 grams is recommended. Use the minimum level of ultrasonic energy to achieve reliable wirebonds. Wirebonds should be started on the chip and terminated on the package or substrate. All bonds should be as short as possible <0.31mm (12 mils).









Notes: